# Modeling of quantum point contacts in high magnetic fields and with current bias outside the linear response regime

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The electron and current-density distributions in the close proximity of quantum point contacts (QPCs) are investigated. A three-dimensional Poisson equation is solved self-consistently to obtain the electron density and potential profile in the absence of an external magnetic field for gate and etching defined devices. We observe the surface charges and their apparent effect on the confinement potential, when considering the (deeply) etched QPCs. In the presence of an external magnetic field, we investigate the formation of the incompressible strips and their influence on the current distribution both in the linear response and out of linear response regime. A spatial asymmetry of the current carrying incompressible strips, induced by the large source drain voltages, is reported for such devices in the nonlinear regime.

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## I. INTRODUCTION

The new era of quantum information processing attracts an increasing interest to investigate the intrinsic properties of small-scale electronic devices. One of the most interesting of such devices is the so-called quantum point contacts (OPCs), where a quantized current is transmitted through it under certain conditions.<sup>1,2</sup> They are constructed on twodimensional electron systems (2DES) either by inducing electrostatic potential on the plane of 2DES and/or by chemically etching the structure. The essential physics is that the small size of the constraint creates quantized energy levels in one dimension (perpendicular to the current direction); therefore, transport takes place depending on whether the energy of the electron coincides with this quantized energy or not. In the ideal case at low bias voltages, if the energy of the electron is smaller than the lowest eigenenergy of the constraint, no current can pass through the QPC. Otherwise, only a certain integer number of levels (channels) are involved, therefore conductance is quantized.<sup>3</sup> Beyond being a useful playground for the basic quantum mechanical applications many other interesting features are reported in literature such as the 0.7 conductance anomaly,  $^{4,5}$  which became a paradigm since then. Another adjustable parameter which induces quantization on the 2DES is the magnetic field B applied perpendicularly to the system. Such an external field changes not only the density of states (DOS) profile of the 2DES but also the screening properties of the system drastically. The interesting physics dictated by this quantization is observed as the quantum Hall effects.<sup>6,7</sup> Recent theoretical investigations point out the importance of the electron-electron interactions in explaining the integer quantum Hall effect,<sup>8,9</sup> believed to be irrelevant in the early days of this field,<sup>10</sup> which we discuss briefly in this work. The basic idea behind the inclusion of the interaction is as follows: Due to the perpendicular magnetic field the energy spectrum is discrete, known as the Landau levels (LLs), and is given by  $E_n = \hbar \omega_c (n+1/2)$ , where n is a positive integer and cyclotron energy is defined

 $\hbar\omega_c = \hbar e B / m^*$ , with effective electron mass  $m^*$ as  $=0.067 * m_e$ . Taking into account the finite size of the sample, i.e., the confinement potential, and the mutual interaction (Hartree) potential, one obtains the total potential. In the next step for a fixed average electron density one calculates the resulting electron-density distribution and from this distribution recalculates the potential distribution iteratively. This self-consistent calculation ends in formation of the compressible and incompressible regions. In a situation where Fermi energy  $E_F$  is pinned to one of the LLs, then the system is compressible. Otherwise, if  $E_F$  falls in between two consecutive LLs, the system is known to be incompressible and, since there are no available states at the  $E_F$  for electrons to be redistributed, screening is poor. However, within these incompressible regions the resistivity vanishes, hence all the applied current is confined to these regions. We will be discussing the details of this model in Sec. IV.

Most recently, the experiments performed at the 2DES including the QPCs, in the presence of an external magnetic field, manifested peculiar results.<sup>11-13</sup> In the first set of experiments electron interference, such as Mach-Zehnder (MZ) (Refs. 11 and 14–18) and Aharonov-Bohm (AB),<sup>19</sup> was investigated. The MZ interference experiments exhibit a novel and yet unexplained behavior, regarding the interference contrast (visibility) at the interferometer in the nonlinear transport regime (finite transport voltage). As a function of voltage, the visibility displayed oscillations whose period was found to be independent of the path lengths of the interferometer, in striking contrast to any straightforward theoretical model [e.g., using Landauer-Büttiker edge states (LBES) (Ref. 20)]. In particular, a new energy scale, of order of  $\mu$  eV, emerged, determining the periodicity of the pattern. This unexpected behavior of interfering electrons is believed to be related to electron-electron interactions.<sup>11</sup> The most satisfying model existing iin literature is proposed by Levkivskyi and Sukhorukov.<sup>21</sup> However, other schemes also including interactions are present<sup>22</sup> and models, which consider a non-Gaussian noise as a source of the visibility oscillations,<sup>23</sup> without interaction. The novel magnetic focusing experiments concerning OPCs have revealed the scattering processes taking place near these devices.<sup>12</sup> It was explicitly shown that the experimental realization of the sample and the device itself strongly affects the transport properties. It is reported that the potential profile generated by the donors (impurities) and the gates deviates strongly from the ideal "point" contact. Even in each cool down process, since the impurity distribution changes, the quantum interference fringes differ considerably. Hence a realistic modeling of a OPC is desirable, which we partially attack in this work. Another interesting set of experiments within the integer quantum Hall regime is conducted by Roddaro et al.,<sup>13</sup> where the transmission is investigated as a function of the gate bias. The findings show that current transmission strongly deviates from the expected chiral Luttinger liquid<sup>24</sup> behavior, since the transmission is either enhanced or suppressed by changing the gate bias. This effect was attributed to the particle-hole symmetry of the Luttinger liquid and is discussed in detail in Ref. 25. However, the explicit treatment of the QPC was left unresolved. Since the essential physics can be still governed by considering a finite-size QPC opening, assuming formation of a (integer) filling region is sufficient.

The theoretical investigation of QPCs covers a wide variety of approaches, which can be grouped into two: (i) the models that include electron-electron interactions and (ii) the models that do not. At the very simple model in describing the OPCs, one considers a potential barrier perpendicular to the current direction quantizing the energy levels. Therefore the electrons are considered to be plane waves before they reach to the QPC and transmission and reflection coefficients are calculated from this potential profile. A better (2D) approximation is to model the QPCs with well defined functions,<sup>26,27</sup> e.g., ellipses, which lead to analytic solutions for the eigenfunctions and energies. About a decade ago Davies and Lorkin<sup>28</sup> developed the "frozen charge" model to calculate the potential profile induced by the gates defining the QPC. This approach is still one of the most used techniques to obtain the potential profile; however, it is not selfconsistent and completely ignores the donors and surface charges. There exist many theories which take the potential profile from the frozen charge model as an initial condition, and provides explicit calculation schemes to obtain charge, current, and potential distributions.<sup>29-33</sup> One of the most complete schemes, even in the presence of an external Bfield, is the local spin-density approximation (LSDA) within the density-functional theory (DFT).34 The LSDA+DFT (Refs. 30, 35, and 36) approaches are powerful to describe the essential physics of density distribution and even 0.7 anomaly phenomenologically, however, the description of the current distribution is still under debate. The scattering problem through the QPCs is usually handled by the "wavepacket" formalism and is very successful in explaining the magnetic focusing experiments. However, the potential profile is not calculated self-consistently and therefore, the effect of the incompressible strips resulting from electronelectron interaction is not taken into account.

Back to early days of the theories that account for electron interactions, i.e., Chklovskii, Shklovskii, and Glazman<sup>37</sup>

(CSG) and Chklovskii, Matveev, and Shklovskii<sup>26</sup> (CMS) models, the influence of the formation of the incompressible strips has been highlighted. In the CMS paper, it was even conjectured that, "the ballistic conductance of the OPC in strong magnetic field is given by the filling factor at the saddle point of the electron density distribution multiplied by  $e^2/2\pi\hbar$ ", which is quantized only if an incompressible strip (region) resides at the saddle point. In one of the recent approaches, in the presence of a strong B field, the electronelectron interaction is treated explicitly within the Thomas-Fermi approximation (TFA) self-consistently, meanwhile the current distribution is left unresolved.<sup>31</sup> In this model, similar to other approaches, the bare confinement potential is obtained from the "frozen charge" approximation, which in turn leads to discrepancies due to its non-self-consistent approach. Here, we improve on this previous work in two main aspects: (i) the electrostatic potential is obtained selfconsistently in three dimensions (3D), which allows us to treat also the etched structures and (ii) the current distribution is calculated explicitly using the local version of Ohm's law, also in the out of linear response regime. We organize our work as follows: In Sec. II, we briefly describe the numerical scheme to calculate the potential profile at B=0 following Ref. 38, which is based on iterative solution of the Poisson equation in 3D. In particular, we study the effect of different gate geometries and focus on the comparison of the potential profiles of gate and etch defined QPCs. The numerical scheme to calculate potential and density profiles at finite temperature and magnetic field is in Appendix A, where we review the essential ingredients of the TFA and discuss the limitations of our approach. Section IV is dedicated to investigating the current distribution within the local Ohm's law.<sup>8,39,40</sup> Both the linear response (LR) and out of linear response (OLR) regimes are investigated. In the OLR, we show that the large current bias induces an asymmetric distribution of the incompressible strips, due to the tilting of the Landau levels resulting from the position dependent chemical potential. We conclude our work in Sec. V where we discuss the experimental implications of our findings, followed by a brief summary in Sec. VI.

#### **II. ELECTROSTATICS IN 3D**

The realistic modeling of 2DES relies on solving the 3D Poisson equation for given boundary conditions, set by the heterostructure (GaAs/AlGaAs in our calculations) and the gate pattern, which describes the charge and potential distribution. The heterostructure, shown in Fig. 1(a), consists of (metallic) surface gates (dark semielliptic regions on surface), a thin donor layer (denoted by light thin layer and  $\delta$  silicon doping) which provides electrons to the 2DES and the 2DES itself indicated by minus signs confined to a thin area. The 2DES is formed at the interface of the heterostructure. The average electron density  $\overline{n_{el}}$  [and its spatial distribution  $n_{el}(x,y)$ ] is dictated by the donor density  $\overline{n_0}$  and the metallic gates. Once the number of donors and the gate voltage  $V_g$  are fixed, the potential and charge distribution of the system can be obtained by solving the Poisson equation self-consistently.

For typical nanoscale devices with many (or at least a few) electrons in each of the electrostatically defined regions,



FIG. 1. (Color online) (a) The silicon doped heterostructure, the 2DES is formed at the interface of the GaAs/AlGaAs (denoted by minus signs) and the metallic gates are deposited on the surface. At zero gate bias, the electron density is determined by the number of donors, which we chose to be  $4 \times 10^{16}$  m<sup>-2</sup>. Charge distribution at different layers obtained by considering a gate voltage -1.7 V, at the gates (b), the dopant layer (c) and the 2DES (d). It is clearly seen that not all the excess electrons are captured by the 2DES, rather a significant amount is accumulated on the surface. The electrostatic quantities are normalized with the relevant scales; i.e., charge (density) is normalized with the average electron density [i.e.,  $Q_{2DES}(x,y)=n_{\rm el}(x,y)/\bar{n}_{\rm el}$ ] and electrostatic potential (energy) with the potential energy of a single electron,  $-{\rm eV}$ .

the charge distribution and the major energy scales are described to a good approximation by classical electrostatics. Due to the strong electric fields generated by segregating charge in a 2DES, the Coulomb energy is the dominant energy scale. In this sense, it is desirable to have a selfconsistent electrostatic description of the system if one expects a good quantitative description thereof.

For solving the electrostatics of the system in three dimensions we used a code developed and successfully applied in previous studies.<sup>38,41</sup> It is based on a fourth-order algorithm operating on a square grid. The code allows flexible implementation of many boundary conditions relevant for nanoscale electrostatics: standard boundaries such as conducting regions at constant voltage (potential gates), of constant charge (large quantum dots) or charge density (doping), but also boundaries such as a depletable 2DEG, dielectric boundaries and surfaces of semiconductors with the Fermi energy pinned due to surface charges. Since the calculation is constrained to a finite volume of space including the surface of the sample, the outer boundary is considered open and is also obtained self-consistently along with the rest of the calculation. Overall the code provides a reliable description of the potential landscape and thus the electric field as well as the charge distribution for the sample under consideration.

As an illustrating example in Fig. 1 we show the heterostructure under investigation together with the charge distributions at different layers. The area of the unit cell is 1.5  $\times 1.5 \ \mu m^2$ , whereas the height is chosen to be 156 nm. The donor and the electron layer lie 43 and 56 nm below the surface, respectively. The metallic gates are deposited on the surface of the structure and are biased with  $V_{p} = -1.7$  V and a homogeneous donor distribution is assumed [Fig. 1(c)]. The induced charge distribution on the metallic gates exhibits apparent inhomogeneities shown in Fig. 1(b). The electrons are accumulated near the boundaries of the gates, a well-known behavior for metallic boundary conditions. However, here we provide the explicit distribution, which strongly differs from the previously used "frozen charge" model where only a constant potential profile is assumed. The influence of these induced charges become more important when considering an external B field, since the steepness of the external potential profile determines the effective widths of the current carrying incompressible strips. We should note that our self-consistent model enables us also to handle the (side) surface charges, which becomes important when considering chemical etching. In the following part we investigate systematically the effects of the gate voltage and the device geometry on the electrostatic quantities.

#### A. Gate defined QPCs

In this section we compare the electron-density profiles calculated for different QPC geometries applying various bias voltages, which exhibit strong nonlinear behavior in contrast to many models used iin literature. We start our discussion with a rather smooth configuration, where the distance between the gates (W) is chosen to be 200 nm [see Fig. 1(a)]. In Fig. 2 we show the electron-density profile for different gate voltages. Interestingly, at  $V_{g}=0$  we see that more electrons are residing beneath the gates. This effect is due to inhomogeneous (induced) charge distribution at the metallic gates similar to the distribution shown in Fig. 1(d). The induced charges are mostly accumulated near the gate boundaries, whereas the center of the gates has almost a constant charge profile. Increasing  $V_g$  to -0.3 V already starts to depopulate electrons under the gates and the depopulation rate remains linear to the applied gate potential until the 2DES becomes depleted. In the [-0.5, -1.2] volt interval, the density distribution changes relatively smooth, since the electrons can still screen the external potential quite well. It is important to recall that, in the absence of an external B field, the DOS of a 2DES is just a constant  $D_0 \ (=m^*/\pi\hbar^2=2.83 \times 10^{10} \text{ meV}^{-1} \text{ cm}^{-2}$  for GaAs), which is set by the sample properties, therefore screening is nearly perfect; whereas this changes considerably when the electrons are depleted under the gate. This is observed by the strong drop of the potential



FIG. 2. (Color online) Spatial distribution of the electrons as a function of the gate voltage. At zero bias (a) more electrons are populated under the gate which changes when depletion starts (b)–(d), where the gate voltage is set to be (b) -0.3 V, (c) -0.7 V, (d) -1.0 V. Almost no electrons are left beyond -1.5 V applied to the gates, (e) -1.5 V, (f) -2.0 V, pinch-off.

when the depletion bias is reached, namely  $V_g \gtrsim -1.3$  V. A sudden variation appears at the potential profile when the electrons are depleted beneath the gates where the  $V_g$  becomes larger than -1.5 V. Therefore, the simple picture describing the QPCs as a smooth function of the applied gate voltage fails. In that picture it is assumed that the Fermi energy of the system remains constant and the potential profile, given by a well defined function, of the constriction is simply shifted by the amount of potential applied to the gates. Such a model is reasonable in the regime where the gate voltage is small enough that no electrons are essentially depleted. However, as mentioned above, when the barrier height is larger than the Fermi energy there exists no electrons to screen the external potential and the potential distribution must be calculated self-consistently.

Another adjustable parameter, which can be accessed experimentally is the geometry of the structure. Of course, in the simplistic models describing QPCs this does not play an important role, since the constriction is assumed to be isotropic in the current direction, in contrast to the experimental findings. It is well known that the shape of the QPCs, as well as the cooling and biasing procedure, is important when measuring interference or magnetic focusing.<sup>12</sup> In Fig. 3, we compare two different gate patterns considering typical gate separations W for a fixed gate voltage,  $V_g = -2.0$  V. The smooth configuration (C1) exhibits a stronger nonlinear behavior when W is changed from 200 nm (black dashed line) to 300 nm (red dashed line). This relies on the fact that, in a first-order approximation, the screening is better when more electrons are accumulated at the opening of the QPC. However, since the screened potential  $V_{scr}(x,y)$  can be obtained from the external potential  $V_{\text{ext}}(x, y)$  via the Thomas-Fermi screening relation,

$$V_{\rm scr}^q = V_{\rm ext}^q / \epsilon(q), \tag{1}$$

where  $\epsilon(q) = 1 + 2/(a_B^*|q|)$  is the Thomas-Fermi dielectric function with q being the momentum and  $a_B^*$  (=9.8 nm for



FIG. 3. (Color online) Potential profile across the QPCs for two different geometrical patterns. The insets depict the smooth (C1) and the sharp edged (C2) patterns. The dark (blue) regions are electron depleted; i.e., the local potential is larger than the  $E_F$ , denoted by the solid thick horizontal line. The white contours denote the depletion boundary, where the width of the QPC is set to be 200 nm and the curvature is changed. The dashed lines stand for the first configuration and two different *W* values [=200 nm (black) and 300 nm (red)], whereas for the sharper configuration four *W* values are shown.

GaAs) the effective Bohr radius, the long range fluctuations (large q), compared to  $a_B^*$ , are less screened whereas the short range fluctuations are predominantly screened. Considering the sharp configuration (C2) this observation becomes more evident, since the potential profile across the QPC varies smoother than of the configuration (C1), when varying W. From an experimentalist's point of view, therefore, drawing sharper QPC structures by electron-beam lithography may lead to a better (linear) control of the potential profile which is closer to the ideal potential profile. This is certainly in contrast to what we would expect from a noninteracting model, however, it is known by the experimentalists that defining the QPCs with sharper edges increases the quality of the visibility signal.<sup>42</sup> For the C2 configuration we also observe that the potential profile becomes almost insensitive to the width W above 300 nm, which coincides with our previous finding of better screening of the long range fluctuations. It is worth to note that our calculation scheme is beyond the simple Thomas-Fermi screening scheme in obtaining the bare confinement potential.<sup>31</sup> It fully takes into account the interaction effects, however, does not include any quantum mechanical effects. In a better approximation, of course, one should also solve the Schrödinger equation self-consistently in 3D. This procedure is known to be costly in terms of computational effort even only if the 2DES is treated quantum mechanically. Since we are interested in either zero or very strong magnetic fields, representing electron as a point charge is still a reasonable and valid approximation. We will discuss the justification of this assumption in the presence of an external magnetic field in more detail in Sec. III and Appendix A, where we also discuss the limitations of our model, Appendix B.

The different configurations of the gate patterns are also important when investigating the scattering processes by magnetic focusing experiments.<sup>12</sup> It is apparent that the scattering patterns of the electron waves will not only depend on the impurity distribution but also on the structure of the QPCs. We expect that for the sharper defined QPC (C2) the scattering should depend weakly on the QPC opening, since the width does not change along the constraint. Whereas, for C1 configuration small changes at W should affect the scattered waves drastically. Another comment on the experimental setups is to the Roddaro<sup>13</sup> experiments, since the formation of (stable) integer filling region is important to explain<sup>25</sup> the findings, we believe that C2-type configurations would be leading to a better resolution of the transmission amplitudes. The choice of the structure and the width apparently depends on the experimental interest, which is believed to be irrelevant when modeling OPCs as ideal point contacts. Note that the QPCs are not only defined by gates but alternatively also by chemical etching. The gated structures are of course more controllable, however, at high gate voltages required for depletion, electrical sparks can occur, therefore the structure can even be destroyed. In such situations etching defined QPCs are preferred, although without further gates one loses the full control of the potential profile. In Sec. II B, we will compare the potential profiles of etched and gate defined OPCs to show that in some cases etch defined OPCs may be more useful to obtain steeper potential profiles.

#### B. Etching versus gating

For simple calculation purposes, QPCs are modeled either as a finite potential well or with a parabolic confinement potential, perpendicular to the current direction. Starting from the early experiments,<sup>1</sup> usually the conductance is measured as a function of the applied gate voltage, which presents clear quantized values. This quantization can be well explained by the Landauer formula<sup>43</sup>

$$G = \frac{e^2}{\pi \hbar} \sum_{n,m=1}^{N_c} |t_{n,m}|^2,$$
 (2)

where ballistic transport is assumed to take place; i.e., the transmission is given by  $|t_{n,m}|^2 = \delta_{n,m}$ , and no channel mixing is allowed. The (integer) number of channels  $N_c$  is defined by the Fermi energy and the width of the constriction, in general. The gate defined QPCs, in a first-order approximation, can be represented by parabolic or finite well potential profiles. However, it is known that the chemical etching process creates (side) surface charges, which in turn generates a steeper potential profile at the edges of the sample. In this situation it is apparent that the confinement potential cannot be assumed to be parabolic, rather a steeper potential should be considered. In this section we compare these two different constriction profiles, namely, the gated and the etched ones.

The self-consistent potential across the QPC at the center is plotted versus the lateral coordinate in Fig. 4. The 2DES under the gates is depleted at  $V_g \ge -1.5$  V, similarly when the etching depth  $D_e$  is larger than 47.7 nm. In both cases, until the depletion is reached the potential profile is varying rather smoothly and the depth of the potential depends linearly on the applied gate bias or the depth. This behavior is



FIG. 4. (Color online) Potential cross section of (a) gated and (b) etched QPCs calculated at selected gate biases and etching depths for C1 for a fixed W=150 nm. The insets focus on the high bias or shallow etching profiles

drastically changed when electrons are depleted; the potential now strongly depends on  $V_g$  or  $D_e$ . Moreover, for the etched structure, potential becomes very steep at the edge of the QPC when  $D_e > 47.7$  nm, i.e., is deeper than the donor layer. The transition from linear behavior to nonlinear behavior is simply due to the significant change of the screening properties of the system. Once the electrons are depleted, the external potential can no longer be screened, therefore the amplitude of the self-consistent potential increases by a large amount. Therefore, screening calculations based on the formula given in Eq. (1) cannot account for such situations, where the dielectric function is not aware of the Fermi energy, i.e., the occupancy. A better approximation to this approach is to consider a Linhard-type dielectric function, which also takes into account the Fermi momentum.<sup>44</sup> It is known that such an improvement will also cover some of the quantum mechanical aspects (such as the extension of the wave functions), which brings extra oscillations to the potential profile.<sup>27</sup> However, for our present interest we neglect this correction knowing that the self-consistency of the calculation scheme already takes into account the occupation and the 1D electron density at the QPC satisfies the validity condition  $n_{\rm el}a_B^* \gg 1$  of the TFA.<sup>31</sup>

We summarize our findings in Fig. 5, where we show the electron density (left) and potential profiles (right) for typical gate biases  $V_g$  and etching depths  $D_e$  versus the spatial coordinate. We choose a representative cross section of the obtained profiles along the current direction x, where the y coordinate is fixed to 450 nm. Figure 5(a) depicts the density profile for selected depths of etching varying from shallow ( $D_e$ =4.7–19.1 nm) to deep ( $D_e$ =38.2–78.4 nm). For the smallest two  $D_es$ , the 2DES is not depleted beneath the pattern and the density profile is rather smooth. Depletion is observed when the depth is larger than 19.1 nm, however, until the etching depth reaches to the depth of 2DES (~60 nm) we do not see the surface charges (the spikelike point, indicated by the arrow) at the level of the 2DES.



FIG. 5. (Color online) Spatial distribution of the electron density [(a) and (c)] and screened potential [(b) and (d)] for etched (upper panel) and gated samples (lower panel), y=450 nm.

inset of Fig. 5(b) shows the electron-density distribution in a color coded contour plot together with the corresponding potential profile across the white (dashed) line. The thin (green) lines contouring the depleted (red) region indicates the spatial distribution of the surface charges. The potential is steeper compared to that of the gated one [Fig. 5(d)] and the profile does not show any considerable variation once the etching depth reaches the plane of the 2DES. This behavior clearly exhibits the uncontrollability of the etched samples, since the corresponding potential profile obtained for the gated samples varies slowly on the length scales of the Fermi wavelength, even if the 2DES is completely depleted beneath the gates. Moreover, the amplitude of the potential strongly depends on the applied gate voltage. The slow variation of the potential is not the case for the etched sample, for example, consider the case when  $D_e$  is changed from 57.3 to 78.4 nm, and compare it with that of the gated sample when voltage is changed from -2.0 to -3.0 V. For the gated sample the potential profile still remains smooth, however, the spatial distribution of the electron density is almost unchanged. Meanwhile, for the deeply etched sample both the electron density and the potential profile are steep and the steepness depends very weakly on the etching depth.

From the above discussion we conclude that for the gated samples the electron-density distribution is weakly affected by the applied gate potential when the depletion is once obtained, meanwhile the potential is smooth and strongly depends on  $V_{\sigma}$ . For the etched samples, potential profile becomes very steep when the etching depth exceeds the depth of the 2DES, since the (side) surface charges pin the Fermi level at the mesa surface to the midgap of GaAs forming a Schottky-type barrier.<sup>45</sup> We should also note that, at zero bias, more electrons are populated under the gates, which is not the case for the etched samples. As a rule of thumb, when a steeper potential profile is required one should consider chemical etching where the etching depth is deeper than the electron layer and one should keep in mind that biasing gates with high potential do not necessarily imply that the electron-density profile is also changed considerably.

The outcome of the self-consistent solution of the 3D Poisson equation considering QPCs at zero magnetic field is

twofold: (i) the geometrical properties (i.e., considering C1or C2-type patterns) strongly change the potential landscape in the close vicinity of the QPCs. We found that the smoother constrictions with a larger width W can be modeled better with the ideal point contacts, i.e., parabolic confinement. The sharper constrictions can be considered as finite well profiles, in a first-order approximation and potential profile remains unchanged when considering W>300 nm. (ii) Due to surface pinning the etched samples generate steeper potential profiles and the density profile remains unaffected once etching is deeper than the depth of the 2DES. These numerical results show a strong deviation from the the widely used "ideal point contact" and "frozen charge" models, proposing that depending on the experimental interest it is important to reconsider the geometrical (C1, C2) and structural (gated/ etched) factors defining the OPC under investigation. As a final remark, the artifacts, such as local minima and maxima at the potential and density profiles, resulting from the previous non-self-consistent Thomas-Fermi<sup>31</sup> and "frozen charge" models<sup>28,30,35</sup> are resolved by considering the 3D calculation scheme.

# III. FINITE B FIELD

The aim of this section and Sec. IV is to calculate, and compare, the density and subsequently the current distributions, in the close vicinity of the OPCs, within interacting and noninteracting models in the presence of an external perpendicular magnetic field. Here we take into account electron-electron interaction within the Thomas-Fermi theory of screening using the potential profiles calculated in Sec. II, as an initial configuration of the landscape. The details of the calculation scheme are presented in Appendix A. Here, we first compare the spatial distribution of the LBES with the distribution of the incompressible edge states, where the applied external current is confined.<sup>8,39,46,47</sup> The limitations of the TFA are discussed in Appendix B, where we suggest improvements on the calculation scheme based on (i) quantum mechanical considerations, such as the finite extension of the wave functions, and (ii) replacement of the global density of states with the local one.

The transport through the QPCs in the absence of an external magnetic field is well described by the Landauer formalism, summarized in Eq. (2). The main idea is that the transport is ballistic and due to the cancellation of the velocity and a 1D DOS,<sup>3</sup> the conductance is integer multiples of the conductance unit,  $e^2/h$ . These integers are just the number of channels  $N_c$ , i.e., the number of eigenenergies below the Fermi energy. A similar path is followed when considering an external B field, which assumes that the conductance is ballistic within 1D channels and neglects the electron interactions. These 1D channels are formed whenever the Fermi energy coincides with a Landau level (Landauer-Büttiker picture). Before proceeding with the full selfconsistent solution of the density and current distribution problem, we first investigate the positions of the Landauer-Büttiker edge states. The procedure is simple; to obtain the energy dispersion we use the relation



FIG. 6. (Color online) The distribution of the spin degenerate LBES at (a)  $\nu \approx 4$  and (b)  $\nu \approx 8$ . The potential cross section at  $\nu = 8$  plateau (c). Sketch of the conductance (G) and expected coherence  $\Xi$  (d) for C1 considering W=150 nm with an applied gate potential  $V_g=2.0$  V, so that the 2DES is depleted beneath the gates. Since spin degeneracy is assumed each edge state carries two units of quantized current.

$$E_{n,k_{u}}(x,y) = E_{n} + V(x,y)$$
 (3)

and follow the equipotential (energy) lines coinciding with the Fermi energy. By doing so we would be able to discuss qualitatively the phase coherence  $\Xi$ , taken to be equal to 1 when there is a full phase coherence and 0 when there is none. We neglect all the external sources of decoherence and assume that the LBES are coherent at the length scales we are interested in; i.e., the wave functions of the associated channels do not overlap.

In Fig. 6, we show the spatial distribution of the expected positions of the LBES at two filling factors. The color scale depicts the self-consistent potential, whereas the black strips show the LBES. The white shaded areas are the electron depleted regions. The  $\nu=2$  and  $\nu=4$  edge states nicely show the expected distribution which are spatially  $\sim 40$  nm apart [Fig. 6(a)]. Depending on the steepness of the potential or the magnetic-field value, however, this distance may become less. For the etched samples (not shown) at the same filling factor the spatial distance between  $\nu=2$  and  $\nu=4$  edge states become almost half the value of the gated samples. For the filling factor  $\nu = 8$  plateau outermost (the ones closest to the gates) two edge states are less than 15 nm apart from each other, and the wave functions extend over a larger distance  $\gtrsim 20$  nm. It is clear that when the two wave functions start to overlap, the coherence  $\Xi$  is reduced drastically. However, for the ideal case (no overlap)  $\Xi$  should stay constant for all plateau regions, since by definition the edge states cannot cross each other. The conductance quantization is, of course, independent of the structure of the ES itself and according to Eq. (2) one should simply count the number of ES, which cross the constriction. The conductance is shown by the sketch in Fig. 6(d); of course the sharp transition between the plateaus is changed when one considers level broadening or in general impurity scattering. One should note that, although the LBES picture is useful in making qualitative arguments, one needs to grasp the actual distribution of the edge states to understand the physics observed at the experiments.<sup>17</sup>

Next we investigate the distribution of the incompressible strips calculated self-consistently described by Eqs. (A5) and (A6). The conductance through the QPC can be rewritten

$$G = \frac{e^2}{h} \nu_{\text{center}} \tag{4}$$

as conjectured in Ref. 26, where  $\nu_{center}$  is the filling factor at the very center of the QPC. It is apparent that, if this value is an integer, i.e., incompressible, the conductance is quantized. Therefore, it is important to study this condition for a realistic QPC geometry. In the following we first calculate the filling factor distribution in the absence of an external current and then obtain the current distribution in Sec. IV.

In order to cure the artifacts arising from TFA (see Appendix B), (i) we consider a Gaussian broadened DOS (Ref. 39) given by

$$D(E) = \frac{1}{2\pi l^2} \sum_{n=0}^{\infty} \frac{\exp[-(E_n - E)^2 / \Gamma_{\rm imp}^2]}{\sqrt{\pi} \Gamma_{\rm imp}}$$
(5)

with the impurity parameter  $\Gamma_{imp}$ , which is chosen large enough  $\Gamma_{\rm imp}/\hbar\omega_c = 0.3$  to cover the level broadening generated by the local electric field<sup>10</sup> and self-consistent broadening effects<sup>48</sup> and (ii) a spatial averaging is carried out over the Fermi wavelength ( $\sim$ 30 nm). Figure 7 summarizes our results showing the spatial distribution of the incompressible ES, considering the quantum Hall plateau  $\nu=2$ . Pedagogically, starting our investigation from large magnetic fields is preferable; at large magnetic fields [Fig. 7(e)], the system is mostly compressible (colored area) and the two incompressible (white) regions do not merge at the opening of the QPC. Therefore, both the Hall resistance and the conductance through the QPC are not quantized. As soon as one enters the QH plateau almost all of the sample becomes incompressible shown in Fig. 7(d) (in the absence of short range impurities) and both  $R_H$  and G become quantized. Decreasing the magnetic field creates two incompressible ES which are spatially separated seen in Fig. 7(b), however, the quantization is not affected. At a lower magnetic-field value these IS-ES disappear [Fig. 7(a)] as an end result of level broadening and (simulation) of the finite extension of the wave functions, now we are out of the QH plateau and G is no longer quantized. This picture and the LBES picture yield same behavior for the  $R_H$  and G, however, in the latter current is carried by the IS-ES, which we will discuss in Sec. IV. The qualitative difference between the two pictures is the coherence as shown by the (red) dashed line in Fig. 7(c). First  $\Xi$  presents minima in between two plateau regimes, since the IS die out, second at the higher edge of the QH plateau the system becomes completely incompressible; therefore, it is not possible to define separate ESs hence coherence is lost (averaged). We believe that this nonuniform behavior of the coherence within the QH plateau coincides with the experimental findings of Roulleau et al.,<sup>18</sup> however, we admit that



FIG. 7. (Color online) Spatial distribution of the incompressible strips (white areas) for characteristic *B* values (a) 6.8 T, (b) 7.3 T, (d) 8.3 T, (e) 8.8 T calculated at temperatures  $\hbar \omega_c / k_B T \ll 1$ , together with the sketch of Hall resistance and the coherence  $\Xi$  (c). The QPC configuration considered here is C1 with *W*=150 nm; the gate voltage is chosen such that all the electrons beneath the gates are depleted.

other explanations are also possible. Another interesting experimental work is carried by the Regensburg group, where they have investigated the amplitude of the visibility oscillations as a function of B field.<sup>17</sup> They have reported a maximum visibility at  $\nu \approx 1.5$ , which seems quite opposite to what has been reported by other groups.<sup>11,18</sup> However, it is easy to see that their sample has a homogeneous width all over, which is not the case for other groups. From selfconsistent calculations<sup>49</sup> it is known that if the sample width is narrower than 5–6  $\mu$ m the center electron density (or filling factor) can differ strongly from that of the average one(s). An indication of such a case is also shown by numerical simulations.<sup>50</sup> In interconnecting the Hall plateaus and the spatial distribution of the incompressible strips, we have used the findings of Ref. 8 where the current is shown to be flowing through the incompressible strips. This is in contrast to some of the models $^{37,51}$  iin literature where the opposite is proposed. In Sec. IV, we will present the general concepts of the local Ohm's law and based on the absence of backscattering in the incompressible strips we will show that the local resistivity vanishes and the external current should be confined to these regions.

# IV. CURRENT DISTRIBUTION WITHIN LOCAL OHM'S LAW

The local (potential) probe experiments<sup>52–54</sup> brought information concerning the Hall potential distribution over the sample. The first set of experiments shows clearly that the potential, therefore the current, distribution is strongly magnetic-field dependent. It was shown that out of the QH plateau the Hall potential varies linearly (type I) all over the sample, a similar behavior to classical (Drude) result. Whereas, at the lower edge of the QH plateau the current is confined to the edges of the sample (type II), which was shown to be coinciding with the positions of the incompressible strips. The most interesting case is observed when an exact (even) integer filling is approached. In these magneticfield values, the potential exhibits a strong nonlinear variation all over the sample, which was attributed to the existence of a large (bulk) incompressible region. The explanation of these measurements acquired a local transport theory, where the conductivities and therefore current distribution can be provided also taking into account interactions. In the subsequent theoretical works<sup>8,39,55</sup> the required conditions were satisfied and an excellent agreement with the experiments were obtained.<sup>52</sup> In the second set of experiments<sup>56</sup> a single electron transistor has been placed on top of the 2DES and the local transparency, i.e., whether the system is compressible or incompressible, and the local resistivity has been measured. Comparing the transparency and the longitudinal resistivity, it has been concluded that the resistivity vanishes when the system is incompressible.

Theoretically, if the local electrostatic potential and the resistivity tensor  $\hat{\rho}(x,y)$  are known the current distribution  $\vec{j}(x,y)$  can be obtained from the local version of the Ohm's law,

$$\vec{E}(x,y) = \hat{\rho}(x,y) \cdot \vec{j}(x,y), \tag{6}$$

provided that

$$\vec{E}(x,y) = \nabla \mu^*(x,y)/e, \qquad (7)$$

where the electrochemical potential is position dependent when a fixed external current  $I = \int_A \vec{j}(x, y) dx dy$  is imposed. In our calculations we assume a local equilibrium in order to describe the stationary nonequilibrium state generated by the imposed current, starting from a thermal equilibrium state obtained from the modified TFA. At this point if the local resistivity tensor is known, Eqs. (6) and (7) should be solved once again iteratively for a given electron density and potential profile, where the equation of continuity

$$\nabla \cdot \mathbf{j}(\mathbf{r}) = \mathbf{0} \tag{8}$$

holds. We assume that the local resistivity is related to the local electron density via the conductivity tensor, i.e.,  $\hat{\rho}(x,y) = \hat{\sigma}^{-1}[n_{\rm el}(x,y)]$ . For a Gaussian broadened DOS the longitudinal component of the conductivity tensor is obtained from

$$\sigma_l = \frac{2e^2}{h} \int_{-\infty}^{\infty} dE \left[ -\frac{\partial f}{\partial E} \right]_{n=0}^{\infty} \left( n + \frac{1}{2} \right) \left[ e^{\{-\left[ (E_n - E)/\Gamma_{\rm imp} \right]^2 \}} \right],$$
(9)

whereas Hall component is simply

$$\sigma_H = \frac{2e^2}{h}\nu,\tag{10}$$

where we ignored the self-energy corrections depending on the type of impurity scatterers. We should emphasize that the above conductivities are used for consistency reasons, in principle, any other reasonable impurity model such as the commonly used self-consistent Born approximation (SCBA) (Refs. 8 and 44) can be considered. Assuming that TFA is valid, we can replace the local conductivities with the above defined global ones.

In the absence of an external current our calculation scheme is as follows: We initialize Eq. (A5) using the total potential obtained from the 3D calculations and obtain the electron density at relatively high temperatures  $(kT/\hbar\omega_c)$  $\sim 0.5$ ) and use this density distribution to obtain resulting potential from Eq. (A6). Next we keep on iterating until a numerical convergence is reached, where the electron density is kept constant. This is followed by the step where the temperature is lowered by a small amount and the iteration process is repeated until the target temperature is reached. After the thermal equilibrium is obtained, we impose a small amount of external current and solve Eqs. (6) and (7) selfconsistently. While doing this second iteration, we fix the constant arising from the integral equation to a value such that the total number of electrons is kept constant with and without current. As a numerical remark, if the current loop does not converge we increase the temperature by a relevant amount and start the iteration procedure. The whole calculation scheme is composed of three different codes, which are written in C++, FORTRAN, and MATLAB, respectively. In order to obtain reasonable grid resolution parallel computation techniques were used.<sup>57</sup>

Since we are interested in current distribution and also its effect on the density distribution we find it appropriate to present our results in two separate sections (i) where the applied current is weak enough that the electron and potential distribution is unaffected, linear response and (ii) the applied current is sufficiently large so that the imposed current induces a considerable change in the position dependent electrochemical potential, out of linear response.

#### A. Linear response regime

The crucial part of the local approach is that for a given (large) magnetic field we can calculate the local potentials and electron distributions self-consistently. The result of such a calculation is that the 2DES is essentially separated in two regions, i.e., compressible and incompressible; therefore for a given (obtained) density we can calculate the local conductivities via Eqs. (9) and (10). Let us now discuss the distinguishing conductance properties of these two regions starting from a compressible region. At a compressible region the Fermi energy is pinned to one of the Landau levels, screening is nearly perfect, self-consistent potential is flat, and filling factor is locally a noninteger and the longitudinal conductivity is nonzero, meaning finite backscattering. Now the classically defined drift velocity and also its quantum me-

chanical counterpart are proportional to the electric field perpendicular to the current direction. We have seen that at the compressible region the potential perpendicular to the current direction is flat, therefore the x component of the electric field is zero, hence the drift velocity. Meanwhile, at an incompressible region the Fermi energy is in between two Landau levels, the filling factor is fixed to an integer value and potential presents a variation perpendicular to the current direction. Due to the Landau gap the longitudinal conductivity vanishes, whereas the Hall conductivity assumes its (quantized) integer value. If one calculates the inverse of the conductivity tensor for the longitudinal component one obtains

$$\rho_l(x,y) = \frac{\sigma_l(x,y)}{\sigma_l^2(x,y) + \sigma_H^2(x,y)},\tag{11}$$

thus the longitudinal resistivity vanishes within the incompressible region pointing the absence of backscattering. Of course, the simultaneous vanishing of both the longitudinal resistivity and the conductivity is a result of applied external (and perpendicular) B field and is obtained only in two dimensions. Moreover, since the x component of the electric field is now nonzero, the drift velocity is finite and the current is confined to this region. Combining these two one concludes that if there exists an incompressible region somewhere in the sample all the external current is confined to this region otherwise (if there are no incompressible regions and all the systems are compressible) the current is distributed according to Drude formalism; i.e., the current density is proportional to the electron density.

We start our discussion of the current distribution when a small current is imposed for which the electrostatic and electrochemical potential satisfies the linear response relation

$$V[(x,y);I] - V[(x,y);0] \approx \mu^*[(x,y);I] - \mu^*_{eq}.$$
 (12)

This condition essentially states that the imposed current does not modify the electrochemical potential; therefore, the electron density remains unchanged. Figure 8 presents the current distribution, which is calculated for the density distribution shown in Fig. 7. The correspondence between the positions of the incompressible strips and the current density is one to one. In the out of plateau regime the current is essentially distributed all over the sample, where no incompressible regions exist [Fig. 8(a)]. As soon as one enters the QHP, i.e., when a large bulk incompressible strip (region) is formed, the essential feature of current distribution is not affected strongly, however, in this situation current is flowing in the incompressible region. Tracking the positions of the ISs in Fig. 7(b), we can readily guess the distribution of the current density in Fig. 8(b). Following our arguments about the smearing out of the narrow incompressible strips, we have a situation in which, again, the current is spread over the sample shown in Fig. 8(a). Although the IS vanishes the reminiscence of it still provides a narrow strip of small longitudinal resistivity and therefore a higher amount of current is kept confined to these regions. Figure 8(c) presents the corresponding longitudinal resistance, when measured as a function of *B* together with the conductance across the QPC. The relation between G and  $R_L$  is interesting, the conduc-



FIG. 8. (Color online) The local current density calculated at different field strengths, same as in Fig. 7. The intensity of the current density is chosen such that the applied current does not effect the density distribution, i.e.,  $|j(x,y)| \sim 0.4 \times 10^{-3}$  A/m.

tance is quantized, as soon as  $R_L$  vanishes at large fields, however, becomes nonquantized even though the  $R_L=0$  at the lower edge of the zero resistance state. Let us first discuss the B dependence of the  $R_I$ ; it is finite if the system is compressible and is zero if an incompressible strip percolates from one edge of the sample to the other edge in the current direction, i.e., from source to drain. Therefore, existence of a percolating IS is sufficient enough to measure zero longitudinal resistance. However, to have a conductance quantization the center of the QPC should be incompressible, which is a stronger restriction.<sup>26</sup> Hence, in the lower edge of the QHP, the IS percolates but the center of the QPC is compressible. The implication of this fact to the coherence is a bit more complicated. We have seen that as soon as one enters the QHP a large bulk IS is formed therefore the phase of the electrons is highly averaged. This implies that the coherence is relatively less than that of the two well separated ISs. On the other hand, at the lower edge of the conductance plateau, the ISs become narrower and are less immune to decoherence effects arising from the environment, hence, the coherence is reduced. Our above discussion coincides with the recent experiments performed in small Mach-Zehnder interference (MZI) devices, where the visibility is measured as a function of the external magnetic field.<sup>18</sup> It is fair to note that some other mechanisms providing B dependence of decoherence can also account for such a behavior.

In the mentioned MZI experiments<sup>11,14</sup> and also the measurements performed by the group of Roddaro<sup>13</sup> a finite (and large) source drain voltage  $V_{SD}$  is applied either to measure



FIG. 9. (Color online) The local filling factor distribution and the corresponding local current density calculated at the default temperature. The current intensity is sufficiently high  $(|j(x,y)| = 2.0 \times 10^{-2} \text{ A/m})$  to induce an asymmetry on the density distribution via position dependent electrochemical potential.

the  $V_{\rm SD}$  dependency of the visibility or the transmission. The intensity of the applied current, in these experiments, cannot be treated within the linear response regime, where the electrochemical potential remains constant, i.e., position independent. In Sec. IV B, we present the current and the density distribution calculated where Eq. (12) does not hold anymore.

#### **B.** Beyond linear response

In the absence of an external current an equilibrium state is obtained by solving Eqs. (A5) and (A6) self-consistently. Even in the presence of a small current, a Hall potential is generated which, in principle, modifies the electrochemical potential, i.e., tilts the Landau levels. This modification can be compensated by the redistribution of the electrons, which certainly modifies the total electrostatic potential. If the applied current is sufficiently small, the modification is negligible, i.e., linear response. However, if the current is large, the resulting Hall potential is also large and one should recalculate the electron density, and therefore the potential distribution until a steady state is reached. In this section we present the current and density distribution in the presence of a large external current, where a local equilibrium is assumed implicitly. Figure 9(a) shows the electron-density distribution in color scale for B=7.1 T, where the intensity of the applied current is in the out of linear response regime. Note that the *B* value is chosen such that the Hall resistance is quantized, however, the conductance is not. The general behavior is similar to that of linear response, however, it is clearly seen that the widths of the ISs are asymmetric with respect to x=750 nm line, where current is driven in y direction. The asymmetry is induced by the large current, since the electrons are redistributed according to the new (selfconsistent) potential distribution. The corresponding currentdensity distribution is plotted in Fig. 9(b), once more the one to one correspondence between the positions of the ISs and the local current maxima is apparent. The consequence of the asymmetry and thereby the widening of the ISs can be observed in the conductance and the  $R_{I}$ , such that the narrow IS at the upper side is smeared out much earlier than the one on the lower side. We should note that such large currents heat the sample therefore the local temperature within the ISs is larger compared to the lattice temperature due to Joule heating.<sup>58</sup> Such a (local) temperature dependence is treated explicitly by Kanamaru and his co-workers<sup>59</sup> and strong evidence is provided toward explaining the breakdown of the IQHE within this approach. Our present approach lacks such a treatment, therefore the competition between the widening of the ISs and heating due to large currents is thought to be more complicated than presented here. As a consequence, the discussion of the coherence is far beyond our model, however, we think that the amplitude of the current when measuring visibility<sup>18</sup> is assumably still in the linear response regime.

In conclusion, by exploiting the local equilibrium and the properties of a steady state we have calculated the current distribution near a QPC in the out of linear response regime. We have shown that an asymmetry is induced on the density profile due to the bending of the Landau levels generated by the large Hall potential. We estimate that the system can still be considered in the linear response regime if the 1D current density is smaller than  $0.042 \times 10^{-2}$  A/m, which certainly depends on the details of the sample geometry.

# V. RELEVANCE OF OUR MODEL CALCULATIONS TO THE EXPERIMENTS

Besides the interference<sup>11,15,16,19</sup> and transmission<sup>13</sup> experiments related with QPCs mentioned in the previous sections, here, we would like to discuss the implications of our model to simple experimental setups only consisting of a single QPC. We should note that our discussion holds for any gate or etched defined narrow constrictions, in general.

The difference between gated and etched defined 2DES has been discussed iin literature<sup>26,60</sup> in terms of analytical calculation schemes. However, the applications to the experimental systems are left unresolved. These models are not addressing the questions that we raise about the QPCs. Here, we suggest a "reasonably easy to realize" experimental setup involving QPCs, to test our model calculations considering these two different potential profiles. The idea is simple, however, fundamental: In Sec. II, we have shown that the smooth QPC configuration, namely, C1, presents a confinement potential which is more or less like a parabola (cf. Fig. 3). This implies an energy dispersion which increases linearly with the state number *n*. On the other hand, the C2 configuration deviates from the parabolic behavior, and pre-

sents a finite well potential profile in the high bias limit, which has an energy dispersion proportional  $n^2$ . Such a difference in the energy dispersion should be observable at the transport properties, when considering different sample geometries (i.e, C1- and C2-like) and QPC widths, *W*.

It would also be interesting to observe that after reaching the saturation potential amplitude,  $V_G > -1.5$  V (cf. Fig. 5) at the gate defined QPCs, it is not possible to change the slope of the electron density by applying higher voltages on the gates. In fact, such a behavior is already observed in gate defined quantum Hall bars<sup>61,62</sup> using the incompressible edge states. Similar behavior is expected considering QPCs. We believe that interference experiments are the correct address to look at such a behavior.

Our calculations considering the finite *B* regime also provide a couple of interesting effects, which could be also tested experimentally at the interference setups. As is well known, interference occurs only if scattering processes take place, i.e., partitioning of the charge carriers. Here, we have shown that the current carried by the incompressible strips can be split without generating noise, therefore no interference can be observed. Such a situation is observed experimentally,<sup>63</sup> however, it has to be investigated in detail.

The most striking feature that is presented in this work is the asymmetric distribution of the incompressible strips near the close vicinity of the QPCs. Since in experiments one can control the two gates constituting the QPC separately, it should be possible to equalize the widths of the incompressible strips at OLR. Certainly, such an effect can be observed at the interference setups, when driving a large dc. As we have mentioned above, if the two incompressible strips merge at the center of the QPC, no noise (therefore, interference) will be generated. Now, we suggest that by playing with the gate voltages on two sides of the QPC separately, one can reach an equilibrium situation in the OLR, where the noise can be switched on and off. Another experimental setup is already proposed considering asymmetrically defined quantum Hall bars,<sup>64</sup> which facilitates the current induced asymmetry to observe different quantized Hall plateau widths by changing the current polarization. The experimental work is underway.<sup>62</sup>

## VI. SUMMARY

In this paper, we provided a self-consistent scheme to obtain the electron density, the potential profile, and the current distribution in the close vicinity of a QPC, within the Thomas-Fermi approximation. Starting from a lithographically defined 3D sample, we calculated the charge distribution at the surface gates, at the plane of 2DES and for etched samples at the side surfaces. The 3D self-consistent solution of the Poisson equation enabled us to present the similarities and differences between an etched and gate defined QPC. We found that the relatively deep etched samples present a sharp potential profile near the edges of the sample. If the depth of the etching exceeds the depth of the 2DES, surface charges are calculated explicitly. In the presence of a quantizing perpendicular magnetic field, we have calculated the distribution of the incompressible strips as a function of the field strength. We have argued that if an incompressible strip becomes narrower than the magnetic length and/or if the transverse electric field is sufficiently large, due to Level broadening, the narrow incompressible strip is smeared. In the next step, the current distribution is obtained both in the linear response and out of linear response regimes using a local version of Ohm's law assuming a steady state at local equilibrium. It is shown that the current is confined to the incompressible strips, due to the absence of backscattering, otherwise it is distributed all over the sample. We have commented on the relation between the existence and percolation properties of the incompressible strips and the measured quantities such as the longitudinal resistance and conductance across the QPC. For the ideal clean sample, i.e., in the absence of long range fluctuations, it is shown that the OH plateau extends wider than that of the conductance plateau. In the out of linear response regime, a current induced density asymmetry is presented in such geometries under quantized Hall conditions. The observable effects of such an asymmetry are not clarified, since it is also known that large currents increase the temperature locally due to Joule heating. However, at the gate defined Hall bars the asymmetry is clearly observed, while the cooling power of the cryostat is high enough.

A natural extension of the existing model is to include the spin degree of freedom and thereby exchange and correlation effects.<sup>65</sup> A local spin-density-functional theory approach<sup>35,36</sup> is the much promising one among others such as Monte Carlo<sup>66</sup> and exact diagonalization, from computational and application point of view. In fact, such an approach already exists, however, the current is handled within the Landauer-Büttiker formalism, which we think is not reasonable in the presence of large incompressible strips. On the other hand, a time dependent spin-density-functional model would be a good candidate to describe current for the geometries under investigation. The implementation of Akera's theory, i.e., Joule heating, to our model is of course desirable, which has been worked presently.

Finally, in order to have a predictive power on the interference experiments we would like to utilize the existing coherent transport models in describing the current together with our electrostatic model, which we are not able to at present. Another challenge is to simulate the real experimental geometries, which already include more than a single QPC and contacts, etc. The numerical routine we developed is now able to do such large scale calculations within the linear response regime, however, it still lacks describing the exchange and correlation effects.

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#### APPENDIX A: THOMAS-FERMI APPROXIMATION (TFA)

The enormous variety of the theories describing the density and current distributions at the quantum Hall systems<sup>8,20,37,39,46,47,67</sup> already show the challenge in giving a proper prescription to these quantities. These theories can be grouped into two: the current is carried either (i) by the compressible regions.<sup>37,51,68</sup> or (ii) by the incompressible regions.<sup>8,39,46,47,69</sup> Moreover (and confusingly) these regions can reside at the bulk<sup>10,67</sup> or at the edge of the sample, <sup>8,37,39,46,59,68</sup> depending on the model considered and the magnetic-field strength.<sup>8</sup> For the sake of completeness, we start with a generic Hamiltonian describing an electron subject to high magnetic fields,

$$H^{\sigma} = H_0 + V_{\text{int}}^{\sigma} + V_{\text{ext}} + V_Z^{\sigma}, \qquad (A1)$$

where  $\sigma(=\pm 1/2)$  is the spin degree of freedom,  $H_0$  is the kinetic part,  $V_{\text{ext}}$  and  $V_{\text{int}}$  are the external and the interaction potentials, respectively, and  $V_Z^{\sigma}$  is the Zeeman term.<sup>70</sup> Our first assumption is to neglect the spin degeneracy, knowing that the effective band g-factor for the GaAs/AlGaAs heterostructures is a factor of 4 less than the one of a free electron gas, and therefore Zeeman splitting is much smaller than the Landau splitting  $\hbar\omega_c$ , i.e.,  $|g^*\mu_B B|/\hbar\omega_c \approx 0.027$ , where  $\mu_B$  is the Bohr magneton. However, Zeeman splitting can be as large as the Landau splitting if exchange and correlation effects are taken into account at significantly high magnetic fields, hence filling factor  $\nu (=E_F/\hbar\omega_c)$  one plateau can be observed experimentally. On the other hand, for higher filling factors  $\nu > 1$  exchange and correlation effects are assumed to be small and Zeeman splitting is negligible. Thus one can consider spinless electrons in the magnetic-field interval we are interested in, which yields to the effective Hamiltonian,

$$H^{\text{eff}} = H_0 + V_{\text{ext}}(x, y) + V_{\text{int}}(x, y).$$
 (A2)

The kinetic part,  $H_0$ , can be solved analytically using the Landau gauge which yield plane-wave solutions in one direction (y) and Landau wave functions in the other direction (x). Here, implicitly, a long Hall bar (ideally infinite) is assumed, which is justified while the Fermi wavelength is (~30-40 nm) much smaller than the sample length under consideration ( $L_y \sim 1500$  nm). Then the eigenfunctions of  $H_0$  can be expressed as

$$\Phi_{n,k_y}(x,y) = \frac{1}{\sqrt{2^n n! \sqrt{\pi l L_y}}} \exp(ik_y \cdot y) \exp\left[\frac{-\left(\frac{x-X}{l}\right)^2}{2}\right]$$
$$\times H_n\left(\frac{x-X}{l}\right), \tag{A3}$$

where  $k_y$  is the quasicontinuous momentum in y direction, n is the Landau index,  $X = -l^2 k_y$  is a center coordinate, and  $H_n(\xi)$  is the nth order Hermite polynomial with the argument  $\xi$ , whereas the eigenenergies are

$$E_n = \hbar \,\omega_c (n+1/2). \tag{A4}$$

The essence of the TFA relies on the fact that the potential profile varies smoothly on the quantum mechanical length scales. Throughout this work we will only consider the 6-8

T interval and as a rough estimation the extension of the wave functions in *x* direction (of the ground state, i.e.,  $\nu$ =2), or the magnetic length  $l = \sqrt{\hbar/m\omega_c}$ , will be always similar or less than 10 nm, therefore in almost all cases neglecting the finite extension of the wave functions is still reasonable. However, we have already seen that for the etched samples the potential is quite steep and the results obtained from the TFA may be doubted, which we will address in Appendix B.

At the moment let us consider a case that the condition of TFA holds; i.e., the total potential  $V_{tot}(x,y) = V_{ext}(x,y)$  $+V_{int}(x,y)$  varies smoothly on the quantum-mechanical length scales and the sample is long enough (i.e.,  $k_F L_y \ge 1$ ). Then we can replace the wave functions in both directions by wave packets centered at X and at y, and the center coordinate dependent eigenenergy  $E_n(X)$  can be approximated to  $E_n + V_{tot}(X, y)$ . It follows that the spatial distribution of the electron density within the TFA is given by the expression<sup>31,32,71</sup>

$$n_{\rm el}(x,y) = \int D[E,(x,y)] f[E + V_{\rm tot}(x,y) - \mu^*] dE, \quad (A5)$$

with D[E, (x, y)] as (local) density of states,  $f(E) = 1/[\exp(E/k_bT)+1]$  as the Fermi function,  $\mu^*$  as the electrochemical potential, which is a constant in equilibrium state,  $k_B$  as the Boltzmann constant, and *T* as the temperature. Once the electron density is obtained, the interaction potential, i.e., the Hartree potential, can be obtained from

$$V_{\rm int}(x,y) = \frac{2e^2}{\bar{\kappa}} \int_A K(x,y,x',y') n(x',y') dx' dy'.$$
(A6)

Here,  $\bar{\kappa}$  is an average dielectric constant (=12.4 for GaAs) and K(x, y, x', y') is the solution of the 2D Poisson equation satisfying the boundary conditions dictated by the sample. The results reported in this and Appendix B assume periodic boundary conditions, where a closed form of the kernel K(x, y, x', y') can be obtained analytically.<sup>72</sup> Equations (A5) and (A6) form a self-consistent loop to obtain the potential and the density profiles of a 2DES subject to high perpendicular magnetic field in the absence of an external current at equilibrium, which has to be solved iteratively using numerical methods. The computational effort to calculate electron and potential profiles within the TFA is much less than that of the full quantum mechanical calculation procedures. The results of both agree quantitatively very well in certain magnetic-field intervals where the widths of the incompressible strips  $W_{\rm IS}$  (in which the potential changes strongly) is larger than l. If  $W_{IS} \leq l$  condition is reached, first of all the TFA becomes invalid and the calculation of the electron density should include the finite extension of the wave functions. The underestimation of the quantum mechanical effects leads to existence of artificial incompressible strips both in the non-self-consistent electrostatic approximation (NSCESA) (Refs. 26 and 37) and self-consistent TFA schemes.<sup>45,73</sup> In fact, as early as the NSCESA, the self-consistent schemes which also took into account finite extension of the wave functions already pointed out the suppression of the incompressible strips in certain magnetic-field intervals<sup>74</sup> and also in the recent reports.<sup>8,29</sup> For a systematic comparison of the calculated widths of the incompressible strips within the TFA and the full Hartree approximations, we suggest the reader to check Ref. 8, where a simpler quasi-Hartree scheme is proposed to recover the artifacts arising from TFA.

#### **APPENDIX B: CORRECTIONS TO THE TFA**

Historically, the first implementation of the TFA, including electron interactions, to quantum Hall systems goes back to the seminal work by Chklovskii et al.<sup>37</sup> There it was shown that within the electrostatic approximation the 2DES is divided into two regions, which have completely different screening properties. In this model, a translation invariance is assumed in the current (y-) direction. Due to finite widths of the samples in the x direction the electrostatic potential is bent upward at the edges, therefore the Landau levels,  $E_n(X) = E_n + V(X)$ . Inclusion of the Coulomb interaction and the pinning of the Fermi energy to the Landau levels result in two regions (strips): (i) The Fermi energy is pinned to one of the highly degenerate Landau levels, where the screening is perfect, effective potential is completely flat (metal-like), and electron density varies spatially. (ii) The Fermi energy falls in between two consecutive Landau levels, screening is poor, effective (screened) potential varies (the amplitude of the variation is  $\hbar\omega_c$ ), and electron density is constant over this region. It is apparent that, if the potential varies rapidly on the scale of l, the TFA fails and the results become unreliable. This condition is realized when considering narrow incompressible strips having a width smaller than the magnetic length. Therefore, one should include the effect of wave functions within these narrow strips. One way is, of course, to do full Hartree calculations. We already mentioned the challenges in the computational effort. A simpler approach is to replace the delta wave functions of the TFA with the unperturbed Landau wave functions, i.e., quasi-Hartree approximation<sup>8</sup> (QHA). The findings of the QHA are shown to be more reasonable than of the TFA, which now also includes the finite extension of the wave functions in the close vicinity of the incompressible strips. Therefore, as an end result, when the  $W_{\rm IS} \leq l$  condition is reached the incompressible strip disappears due to the overlap of the neighboring wave functions. Based on this fact, in our calculations we exclude the effects arising from the artifacts of the TFA by considering a spatial averaging of the electron density on the length scales smaller than l, which is known to be relevant in simulating the quantum-mechanical effects.<sup>40,49,75</sup>

We should also make one more point clear in NSCESA; a gate defined quantum Hall bar is considered. However, it is more common to define Hall bars by chemical etching and the edge potential profile is much steeper compared to gated samples, which was shown previously. Therefore, to fit the predictions of this model concerning the widths and the positions of the incompressible strips with the experimental data one has to assume that<sup>52</sup> (i) the 2DES and the gates are on the same plane and (ii) the gate voltage applied should be fixed to the half of the midgap of the GaAs, i.e., pinning of the Fermi energy at the GaAs surface. In fact, after making these two crucial assumptions the experimental findings of Ahlswede<sup>52</sup> perfectly fits with the NSCESA. However, the

widths (and the existence) of the incompressible strips strongly deviate from the predictions, since only the innermost incompressible strip can be observed. We have argued that the widths of the incompressible strips strongly depend on the slope of the potential; i.e., if the external potential is steep the incompressible strips are narrow. Therefore one can easily conclude that since the widths of the outermost incompressible strips, i.e., the ones close to the edge, become smaller than the magnetic length, they could not be observed. The overestimation of the  $W_{IS}$  within the TFA becomes more severe when an external current is imposed to the system, which we discuss in Sec. IV. Before discussing the results of the relaxed TFA, we want to touch on another locally defined quantity, namely, the DOS, and comment on the implementation of the global DOS to our local TFA.

In the absence of impurity scattering the DOS of an infinite (spinless) 2DES is given by the bare Landau DOS as

$$D(E) = \frac{1}{2\pi l^2} \sum_{n} \delta(E - E_n), \qquad (B1)$$

however, this DOS is broadened by the scattering processes, which can be described in self-consistent Born approximation<sup>8,44</sup> accurately for short-range impurity potentials yielding a semielliptic broadening. Of course, other impurity models and scattering processes can also be considered resulting in Gaussian or Lorentzian broadened Landau DOS.<sup>39,76</sup> In such descriptions of the DOS broadening an infinite 2DES is assumed and the DOS is calculated for impurity distributions averaged over all possible configurations. Inserting this (global) DOS in Eq. (A5) can be justified again if the TFA condition is satisfied. We have already shown that this condition is violated when a narrow incompressible strip is formed where the external potential is poorly screened. Therefore, the actual distribution of the impurity potential becomes more effective at these transparent regions. We should also note that the effect of screening on the DOS of an infinite system has been investigated in detail in Ref. 48 and it has been shown that, since the screening is poor within the incompressible regions, the DOS becomes much broader than that of the noninteracting case. Hence, the gap between two consecutive Landau levels is narrower within the incompressible strips compared to compressible strips. Moreover, recently it has been shown that the (local) electric field within the sample also leads to broadening of the (local) DOS.<sup>77</sup> The idea is basically that one calculates the Green's function for the given potential profile, which is a function of the applied magnetic field and external current, and obtains the local DOS from the general expression

$$D[E,(x,y)] = \sum_{n} |\tilde{\Phi}_{n,k_y}(x,y)|^2 \delta(E - \tilde{E}_{n,k_y}), \qquad (B2)$$

where  $\tilde{\Phi}_{n,k_y}(x,y)$  is the *n*th eigenfunction of the Hamiltonian given at Eq. (A2) with the eigenvalue  $\tilde{E}_{n,k_y}$ . In our above discussion about the formation of the compressible/ incompressible strips we have mentioned that the potential varies locally whenever an incompressible strip is formed, where the variation is linear in position up to a first-order approximation. Now let us consider a linear potential profile and reobtain the local DOS (LDOS) following<sup>78</sup> for the *k*th Landau level,

$$D_k(E) = \frac{1}{2^{k+1}k! \pi^{3/2} l^2 \Gamma} e^{-E_k^2/\Gamma^2} [H_k(E_k/\Gamma)]^2, \qquad (B3)$$

with the level width parameter

$$\Gamma = \mathcal{E}_x l, \tag{B4}$$

where  $\mathcal{E}_x = \partial V(x, y) / \partial x$  is the electric field in the *x* direction and  $E_k = E - \Gamma^2 / (4\hbar\omega_c) + (2k+1)\hbar\omega_c$ . The immediate consequence of a strong electric field in the *x* direction is a broadening of the LDOS, which happens at the incompressible strips. On the other hand, since  $\mathcal{E}_x$  vanishes at the compressible strips, the bare Landau DOS is reconstructed from Eq. (B3) in the  $\Gamma \rightarrow 0$  limit.

In summary, the TFA should be repaired when the widths of the incompressible strips are comparable to or less than the magnetic length; since (i) the quantum-mechanical wave functions have a finite extension and do overlap with the neighboring ones (ii) the LDOS are broadened where strong electric fields exist; (iii) within the poor screening regions the (Landau) gap is smaller than the ones of the nearly perfect screening regions. At a very simple approximation these artifacts of TFA are cured by a spatial averaging over the Fermi wavelength resulting in nonexistence of narrow incompressible strips. Throughout this work an appropriate averaging process will be applied.

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